



DOCKET NO: VSEA 02-01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Daniel F. Downey et al.  
Serial No: 09/996,446  
Confirmation No: 2412  
Filed: November 28, 2001  
For: ATHERMAL ANNEALING WITH RAPID THERMAL  
ANNEALING SYSTEM AND METHOD  
Examiner: Jermele M. Hollington  
Art Unit: 2829

**CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8(a)**

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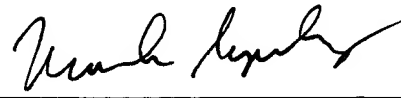
Sir:

Transmitted herewith are the following documents:

- ☒ Final Amendment
- ☒ Request for Continued Examination
- ☒ Petition for Three Month Extension of Time
- ☒ Return Receipt Postcard

If any fees are determined to be required or if there are any overpayments, Deposit Account 50-0896 may be charged or credited.

Respectfully submitted,  
*Daniel F. Downey et al., Applicants*

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